

<b>Notice of References Cited</b>		Application/Control No. 09/813,240	Applicant(s)/Patent Under Reexamination AMMON ET AL.	
		Examiner Johannes P Mondt	Art Unit 2826	Page 1 of 1

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<sup>1</sup>A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a))  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.